



*Receipt*  
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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of: Van Schravendijk, et al

Attorney Docket No.:

NOVLP037C1/NVLS-000519C1

Application No.: 10/773,821

Examiner: UNASSIGNED

Filed: February 5, 2004

Group: 2813

Title: APPLICATIONS AND METHODS OF  
MAKING NITROGEN-FREE ANTI-  
REFLECTIVE LAYERS FOR  
SEMICONDUCTOR PROCESSING

**CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as first-class mail on May 11, 2004 in an envelope addressed to the Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450.

Signed: \_\_\_\_\_

*Leslie Russell*  
Leslie Russell

**REQUEST FOR CORRECTED FILING RECEIPT**

Commissioner for Patents  
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Alexandria, VA 22313-1450

Sir:

Enclosed is a copy of the Filing Receipt for the above-identified patent application. Please reprint the Filing Receipt as follows and mail the corrected copy to the undersigned.

Change Applicant "M. Zlraul Karim" to -- M. Zi~~a~~ul Karim --.

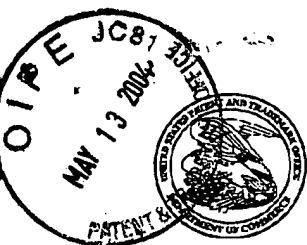
Since this is a Patent Office typographical error, no fee should be due. However, the Commissioner is authorized to charge any fees that may be due to Deposit Account 500388 (Order No. NOVLP037C1).

Respectfully submitted,  
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## UNITED STATES PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/773,821	02/05/2004	2813	770	NOVLP037C1/NVLS-000519C1	5	9	3

CONFIRMATION NO. 8057

022434  
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## FILING RECEIPT



\*OC000000012538268\*

Date Mailed: 05/05/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

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## Assignment For Published Patent Application

Novellus Systems, Inc.;

## Domestic Priority data as claimed by applicant

This application is a CON of 09/990,197 11/21/2001 PAT 6,720,251  
 which claims benefit of 60/302,112 06/28/2001

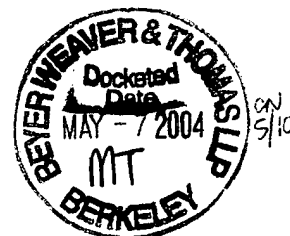
## Foreign Applications

If Required, Foreign Filing License Granted: 05/05/2004

Projected Publication Date: Request for Non-Publication Acknowledged

Non-Publication Request: Yes

Early Publication Request: No



TJW

**Title**

Applications and methods of making nitrogen-free anti-reflective layers for semiconductor processing

**Preliminary Class**

438

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Title 37, Code of Federal Regulations, 5.11 & 5.15**

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